Chapter 5 INTERNAL MEMORY

> Memory cell architecture





Figure 5.1 depicts the operation of a memory cell. Most commonly, the cell has three functional terminals capable of carrying an electrical signal. The select terminal, as the name suggests, selects a memory cell for a read or write operation.

The control terminal indicates read or write. For writing, the other terminal provides an electrical signal that sets the state of the cell to 1 or 0. For reading, that terminal is used for output of the cell's state.

> Dynamic RAM

DYNAMIC RAM technology is divided into two technologies: dynamic and static. A dynamic RAM (DRAM) is made with cells that store data as charge on capacitors. The presence or absence of charge in a capacitor is interpreted as a binary 1 or 0. Because capacitors have a natural tendency to discharge,

Dynamic



(a) Dynamic RAM (DRAM) cell

RAMs require periodic charge refreshing to maintain data storage. The term *dynamic* refers to this tendency of the stored charge to leak away, even with power continuously applied.

Figure 5.2a is a typical DRAM structure for an individual cell that stores 1 bit. The address line is activated when the bit value from this cell is to be read or written. The transistor acts as a switch that is closed (allowing current to flow) if a voltage is applied to the address line and open (no current flows) if no voltage is present on the address line.

Computer memory is the storage space in computer where data is to be processed and instructions required for processing are stored. The memory is divided into large number of small parts called cells. Each location or cell has a unique address which varies from zero to memory size minus one.

> STATIC RAM

In contrast, a static RAM (SRAM) is a digital device that uses the same logic elements used in the processor. In a SRAM, binary values are stored using traditional flip-flop logic-gate configurations (see Chapter 20 for a description of flip-flops). A static RAM will hold its data as long as power is supplied to it.



Figure 5.2b is a typical SRAM structure for an individual cell. Four transistors (T1, T2, T3, and T4) are cross connected in an arrangement that produces a stable logic state. In logic state 1, point C1 is high and point C2 is low; in this state, T1 and T4 are off and T2 and T3 are on.1 in logic state 0, point C1 is low and point C2 is high; in this state, T1 and T4 are on and T2 and T3 are off. Both states are stable as long as the direct current (dc) voltage is applied. Unlike the DRAM, no refresh is needed to retain data.

Comparison between SRAM and DRAM

SRAM	DRAM	
1. SRAM defines as static random access memory.	1. DRAM defines as dynamic random access memory.	
2. SRAM is dense	2. DRAM is more dense	
3. Its dynamic memory cell is complex.	3. Its dynamic memory cell is simpler.	
4. its faster than DRAM	4. its slower	
5. It's expensive.	5. Its less expensive.	
6. It has stored charge capacitor.	6. It has binary values that are stored using as flip/flop.	

> Types of ROM

As the name suggests, a **read-only memory** (ROM) contains a permanent pattern of data that cannot be changed. A ROM is nonvolatile; that is, no power source is required to maintain the bit values in memory.

Programmable ROM (PROM), Like the ROM, the PROM is nonvolatile and may be written into only once. For the PROM, the writing process is performed electrically and may be performed by a supplier or customer at a time later than the original chip fabrication.

The optically **erasable programmable read-only memory** (EPROM) is read and written electrically, as with PROM. However, before a write operation, all the storage cells must be erased to the same initial state by exposure of the packaged chip to ultraviolet radiation.

A more attractive form of read-mostly memory is **electrically erasable programmable read-only memory** (EEPROM). This is a read-mostly memory that can be written into at any time without erasing prior contents; only the byte or bytes addressed are updated. The write operation takes considerably longer than the read operation, on the order of several hundred microseconds per byte.

Another form of semiconductor memory is **flash memory** (so named because of the speed with which it can be reprogrammed). First introduced in the mid-1980s, flash memory is intermediate between EPROM and EEPROM in both cost and functionality. Like EEPROM, flash memory uses an electrical erasing technology. An entire flash memory can be erased in one or a few seconds, which is much faster than EPROM.

Semiconductor Main Memory

The most common form of random-access storage for computer main memory employed an array of doughnut-shaped ferromagnetic loops referred to as *cores*. Hence, main memory was often referred to as *core,* a term that persists to this day. The advent of, and advantages of,

microelectronics has long since vanquished the magnetic core memory. Today, the use of semiconductor chips for main memory is almost universal.

Memory Type	Category	Erasure	Write Mechanism	Volatility
Random-access memory (RAM)	Read-write memory	Electrically, byte-level	Electrically	Volatile
Read-only memory (ROM)	Read-only memory	Not possible	Masks	Nonvolatile
Programmable ROM (PROM)			Electrically	
Erasable PROM (EPROM)	Read-mostly memory	UV light, chip-level		
Electrically Erasable PROM (EEPROM)		Electrically, byte-level		
Flash memory		Electrically, block-level		

Table 5.1 Semiconductor Memory Types

Table 5.1 lists the major types of semiconductor memory. The most common is referred to as *random-access memory* (RAM). This is, of course, a misuse of the term; because all of the types listed in the table is random access. One distinguishing characteristic of RAM is that it is possible both to read data from the memory and to write new data into the memory easily and rapidly.